

Docket No. 214810US90PCT

IN RE APPLICATION OF: Yasutaka ITO, et al.

SERIAL NO: 09/926,296

FILED: December 27, 2001

FOR: CERAMIC SUBSTRATE FOR A SEMICONDUCTOR-PRODUCING/EXAMINING DEVICE



\$1772

ASSISTANT COMMISSIONER FOR PATENTS  
WASHINGTON, D.C. 20231

SIR:

Transmitted herewith is an amendment in the above-identified application.

RECEIVED  
MAY 02 2003  
GROUP 1700

- ☐ No additional fee is required
- ☐ Small entity status of this application under 37 C.F.R. §1.9 and §1.27 is claimed.
- ☒ Additional documents filed herewith: Marked-up Copy; Request for Extension of Time (3 months)

The Fee has been calculated as shown below:

CLAIMS	CLAIMS REMAINING		HIGHEST NUMBER PREVIOUSLY PAID	NO. EXTRA CLAIMS	RATE	CALCULATIONS
TOTAL	10	MINUS	20	0	x \$18 =	\$0.00
INDEPENDENT	1	MINUS	3	0	x \$84 =	\$0.00
		<input type="checkbox"/> MULTIPLE DEPENDENT CLAIMS			+ \$280 =	\$0.00
		TOTAL OF ABOVE CALCULATIONS				\$0.00
		<input type="checkbox"/> Reduction by 50% for filing by Small Entity				\$0.00
		<input type="checkbox"/> Recordation of Assignment			+ \$40 =	\$0.00
		TOTAL				\$0.00

- ☒ A check in the amount of **\$930.00** is attached.
- ☒ Please charge any additional Fees for the papers being filed herewith and for which no check is enclosed herewith, or credit any overpayment to deposit Account No. 15-0030. A duplicate copy of this sheet is enclosed.
- ☒ If these papers are not considered timely filed by the Patent and Trademark Office, then a petition is hereby made under 37 C.F.R. §1.136, and any additional fees required under 37 C.F.R. §1.136 for any necessary extension of time may be charged to Deposit Account No. 15-0030. A duplicate copy of this sheet is enclosed.

OBLON, SPIVAK, McCLELLAND,  
MAIER & NEUSTADT, P.C.

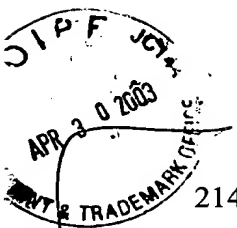
Masayasu Mori

Registration No. 47,301



22850

Customer Number 22850  
Tel. (703) 413-3000  
Fax. (703) 413-2220  
(OSMMN 10/01)



8B  
5/7/03

214810US90PCT

IN THE UNITED STATES PATENT & TRADEMARK OFFICE

IN RE APPLICATION OF:

Yasutaka ITO, et al.

SERIAL NO: 09/926,296

FILED: December 27, 2001

FOR: CERAMIC SUBSTRATE FOR SEMICONDUCTOR-PRODUCING/EXAMINING  
DEVICE

:

: EXAMINER: THOMAS, A.

:

: GROUP ART UNIT: 1772

RECEIVED  
MAY 02 2003  
GROUP 1700

AMENDMENT

ASSISTANT COMMISSIONER FOR PATENTS  
WASHINGTON, D.C. 20231

SIR:

In response to the Office Action dated October 31, 2002, please amend the above-identified application as follows:

IN THE CLAIMS

A clean copy of the claims incorporating any amendment is shown below.

✓  
Please cancel Claims 1-12 without prejudice and add new Claims 13-22 as follows:

7B  
1. ~~13.~~ (New) A ceramic heater for a semiconductor-producing/examining device having a ceramic substrate and a conductor formed on a surface of said ceramic substrate or inside said ceramic substrate,

wherein said ceramic substrate comprises a nitride ceramic or a carbide ceramic, contains oxygen and has a disc form, the diameter thereof exceeding 250 mm and a thickness thereof being 25 mm or less.

B